

Lecture 2.

Granular metals

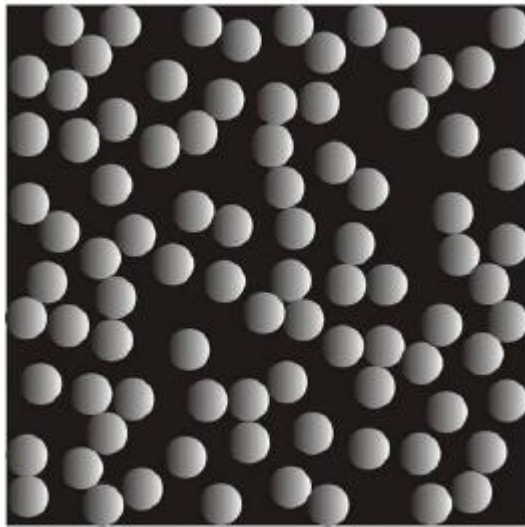
Plan of the Lecture

- 1) Basic energy scales
- 2) Basic experimental data
- 3) Metallic behaviour: logarithmic $R(T)$
- 4) Insulating behaviour: co-tunneling and ES law
- 5) Co-tunneling and conductance of diffusive wire

Review: I.Beloborodov *et al*, Rev. Mod.Phys.**79**, 469 (2007)

Metal grains in an insulating matrix

Grain radius $a \gg \lambda_F$

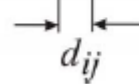


Direct contact of metal grains.

Dimensionless conductance $g \approx \text{const}$



Intergrain tunneling through an insulating gap.



--thickness of insulating layer

Dimensionless conductance:

$$g_{ij} \propto \exp\{-2k_0 d_{ij}\}$$

Strong inhomogeneous fluctuations of g_{ij} due to exponential dependence on d_{ij}

Examples:

Conduction in granular aluminum near the metal-insulator transition

T. Chui, G. Deutscher,* P. Lindenfeld, and W. L. McLean

Phys Rev B 1981

Transport measurements in granular niobium nitride cermet films

R. W. Simon,* B. J. Dalrymple,* D. Van Vechten, W. W. Fuller, and S. A. Wolf

Phys Rev B 1987

Basic energy scales

Grain radius a is large on atomic scale: $k_F a \gg 1$

Coulomb energy $E_c = e^2/a$

Level spacing inside grain $\delta = 1/(4a^3 \nu)$

Intra-grain Thouless energy $E_{th} = \hbar D_0/4a^2$

$$\delta \ll E_{th} \ll E_c$$

Example: Al grains with $a=20$ nm

$$g_0 = E_{th}/\delta = 2500$$

$$\delta = 0.02 \text{ K} \quad E_{th} = 50 \text{ K} \quad E_c = 1000 \text{ K}$$

Typical temperature range $4 \text{ K} < T < 300 \text{ K}$

$$\Gamma \sim 1 \text{ K} \quad \text{for} \quad g_T = 50$$

Intergrain coupling



Intergrain tunneling
through an insulating gap

Low transmission, but large
number of transmission modes

$$\sigma_T = (4\pi e^2/\hbar) \nu^2 \langle |t_{pk}|^2 \rangle$$

$g_T = \sigma_T h/e^2$ - dimensionless inter-grain conductance

A) Granular metal $g_T \geq 1$

Effective diffusion constant

$$D_{\text{eff}} = \Gamma a^2/\hbar \ll D_0$$

Narrow coherent band $\Gamma = g_T \delta \ll E_{\text{th}}$

$\Gamma \sim 1\text{K}$ for $g_T = 50$

B) Granular insulator $g_T \leq 1$

Nearest-neighbors coupling only !

Experimental data: granular metals

Transport measurements in granular niobium nitride cermet films

R. W. Simon,* B. J. Dalrymple,* D. Van Vechten, W. W. Fuller, and S. A. Wolf

Phys Rev B 36 1964 (1987)

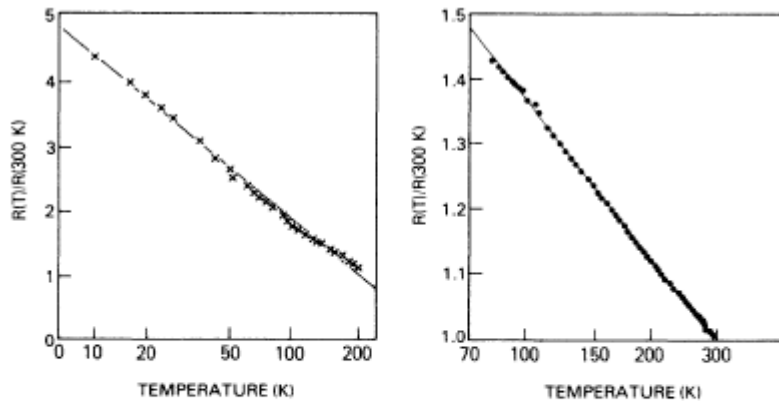


FIG. 5. The resistance normalized to the room-temperature value vs $\ln T$ for two different superconducting samples. The graph on the left is for a sample with $R_{\square}(300 \text{ K}) = 2000 \text{ } \Omega/\square$, while that on the right is for $R_{\square}(300 \text{ K}) = 100 \text{ } \Omega/\square$. The lines are guides to the eye.

$$R(T) = R_0 \ln(T_0/T)$$

Insulator-Superconductor Transition in 3D Granular Al-Ge Films

A. Gerber, A. Milner, G. Deutscher, M. Karpovsky, and A. Gladkikh

Phys Rev Lett. 78, 4277 (1997)

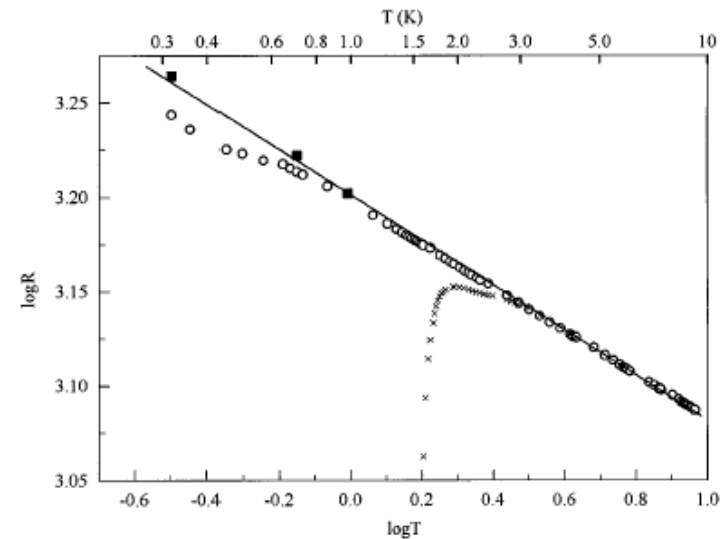


FIG. 3. Resistance of sample 3 as a function of temperature on a log-log scale, as measured at (zero) (\times) and 100 kOe field (open circles). Open circles indicate resistance measured with a constant dc current $I = 10^{-5} \text{ A}$. Solid squares are zero bias resistances approximated from I - V measurements. Sample 3 room temperature resistance is $500 \text{ } \Omega$.

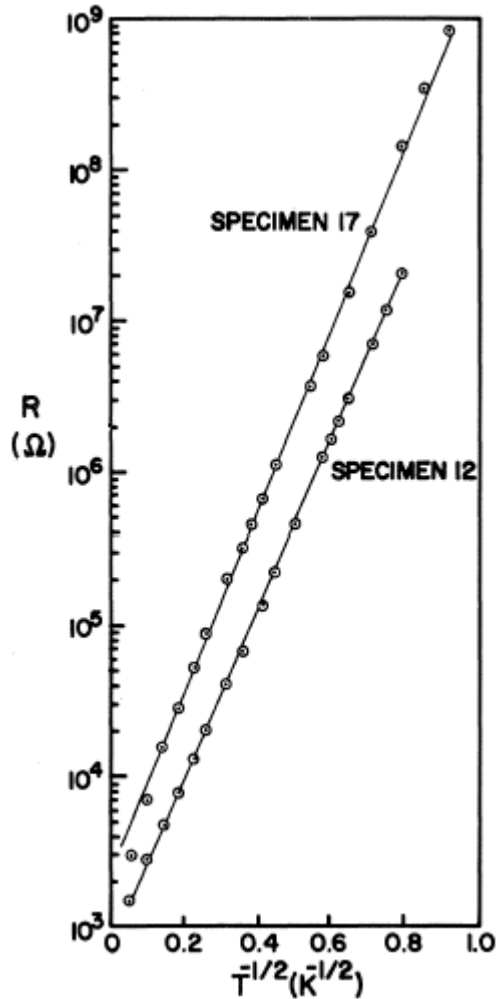
Coefficient in front of the Log is too large for interference corrections (Lecture 1)

Experimental data: granular insulators

Conduction in granular aluminum

T. Chui, G. Deutscher,* P. Lindenfeld, and W. L. McLean

Phys Rev B 23 6172 (1981)



Transport measurements in granular niobium nitride cermet films

R. W. Simon,* B. J. Dalrymple,* D. Van Vechten, W. W. Fuller, and S. A. Wolf

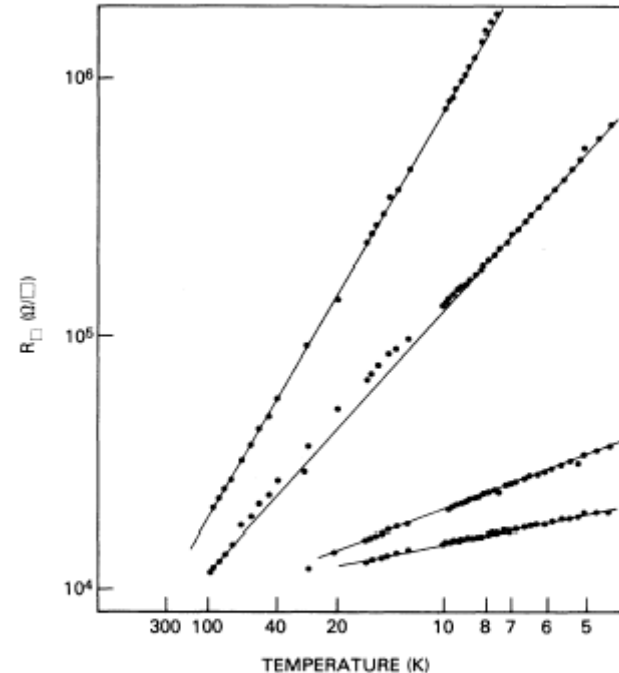


FIG. 4. The logarithm of the sheet resistance as a function of $1/\sqrt{T}$ for a variety of the nonsuperconducting samples. The lines are guides to the eye.

$$R = R_0 \exp(T_0/T)^{1/2} \quad \text{Efros-Shklovsky}$$

Variable-range hopping in presense of Coulomb gap

The origin of VRH ???

3) Metallic behaviour: theory of logarithmic $R(T)$ dependence

Granular structure leads to a new (compared to usual metals) energy window $\Gamma \ll T \ll E_C$ where

- Coulomb energy is very important
- Coherent nature of transport is irrelevant

Useful formulation of the theory is in terms of phase variables

$$\varphi_i(t) = (e/\hbar) \int^t V_i(t') dt' \quad \text{conjugated to grain charges } Q_i$$

The reason: at $g_T \gg 1$ phases are weakly fluctuating

Ambegaokar-Eckern-Schön functional

Phys Rev B **30**, 6419 (1984)

$$Z = \int \exp(-S) D\varphi, \quad S = S_c + S_t$$

Action functional in imaginary (Matsubara) time

S_c describes the charging energy

$$S_c = \frac{1}{2e^2} \sum_{ij} \int_0^\beta d\tau C_{ij} \frac{d\varphi_i(\tau)}{d\tau} \frac{d\varphi_j(\tau)}{d\tau};$$

S_t stands for tunneling between the grains

$$S_t = (1/4) g \sum_{\langle ij \rangle} \int_0^\beta d\tau d\tau' \alpha(\tau - \tau') \sin^2 \left[\frac{\varphi_{ij}(\tau) - \varphi_{ij}(\tau')}{2} \right]$$

$$\alpha(\tau - \tau') = T^2 \text{Re} \sin^{-2} [\pi T(\tau - \tau' + i\eta)]$$

Perturbation theory

Quadratic approximation for the action: $S_0 = T \sum_{\mathbf{q}, n} \varphi_{\mathbf{q}, n} G_{\mathbf{q}, n}^{-1} \varphi_{-\mathbf{q}, -n}$

$$G^{-1} = (\omega_n^2 / 2e^2) C(\mathbf{q}) + (1/\pi) g_T |\omega_n| \beta(\mathbf{q})$$

$$\omega_n = 2 \pi n T$$

$$\beta(\mathbf{q}) = \sum_a (1 - \cos \mathbf{q} \mathbf{a})$$

$$\langle (\varphi_{ij}(0) - \varphi_{ij}(\tau))^2 \rangle \sim (1/g_T) \sum_n (1 - \cos \omega_n \tau) / [|\omega_n| + \omega_n^2 / E_C g_T]$$

High-energy cutoff $E_C g_T = 1/(RC)$

Low-energy cutoff $1/\tau$

$$\langle (\varphi_{ij}(0) - \varphi_{ij}(\tau))^2 \rangle \sim (1/g_T) \ln (E_C g_T \tau)$$

Intergain conductivity

Efetov, K. B., and A. Tschersich, 2003, Phys. Rev. B **67** 174205.

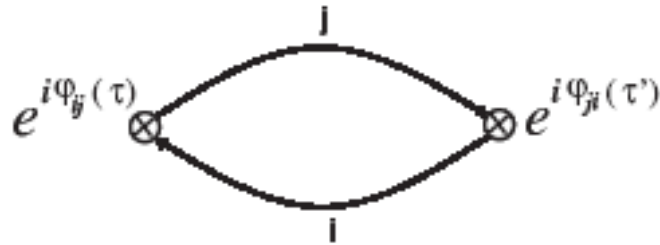


FIG. 9 This diagram represents the conductivity in the leading order in $1/g$. The crossed circles represent the tunnelling matrix elements $t_{kk'}^{ij} e^{i\varphi_{ij}(\tau)}$ where phase factors appear from the gauge transformation.

$$\sigma(\omega) = \frac{2\pi e^2 g T^2 i a^{2-d}}{\omega} \int_0^\beta d\tau \frac{1 - e^{i\Omega\tau}}{\sin^2(\pi T\tau)} \exp\left(-\tilde{G}_{\mathbf{a}}(\tau)\right)$$

where the analytic continuation to the real frequency is assumed as $\Omega \rightarrow -i\omega$ and the function $\tilde{G}_{\mathbf{a}}(\tau)$ is

$$\tilde{G}_{\mathbf{a}}(\tau) = 4T a^d \sum_{\omega_n > 0} \int \frac{d^d \mathbf{q}}{(2\pi)^d} G_{\mathbf{q}n} \sin^2 \frac{\mathbf{q}\mathbf{a}}{2} \sin^2 \frac{\omega_n \tau}{2}.$$

1st logarithmic correction:

$$g_T(T) = g_T - (4/z) \ln (g_T E_C / T)$$

here z is the lattice coordination number

The origin of this correction: discreteness of charge transfer. Formally, it is represented as non-linearity of the AES action in phase representation. Phase (voltage) fluctuations across each tunnel junction destroy coherence of electron states in neighboring grains, and suppress inter-grain conductivity.

Contrary to usual logarithmic corrections in 2D metals, this effect does not depend on dimensionality

Renormalization group

$$S_t = (1/4) g \sum_{\langle ij \rangle} \int_0^\beta d\tau d\tau' \alpha(\tau - \tau') \sin^2 \left[\frac{\varphi_{ij}(\tau) - \varphi_{ij}(\tau')}{2} \right]$$

Split phase variables into slow and fast parts

$$\phi_{ij\omega} = \phi_{ij\omega}^{(0)} + \bar{\phi}_{ij\omega}$$

where the function $\phi_{ij\omega}^{(0)}$ is the slow variable and it is not equal to zero in an interval of the frequencies $0 < \omega < \lambda\omega_c$, while the function $\bar{\phi}_{ij\omega}$ is finite in the interval $\lambda\omega_c < \omega < \omega_c$, where λ is in the interval $0 < \lambda < 1$.

Renormalization group -2

Substituting Eq. (2.66) into Eq. (2.65) we expand the action S_t up to terms quadratic in $\bar{\phi}_{ij\omega}$. Integrating in the expression for the partition function

$$Z = \int \exp(-S_t[\phi]) D\phi$$

over the fast variable $\bar{\phi}_{ij\omega}$ with the logarithmic accuracy we come to a new renormalized effective action \tilde{S}_t

$$\begin{aligned} \tilde{S}_t = & 2\pi g \sum_{\langle i,j \rangle} \int_0^\beta \int_0^\beta d\tau d\tau' \alpha(\tau - \tau') \\ & \times \sin^2 \left[\frac{\phi_{ij}(\tau) - \phi_{ij}(\tau')}{2} \right] \left(1 - \frac{\xi}{2\pi g d} \right) \end{aligned}$$

where $\xi = -\ln \lambda$.

It follows from Eq. (2.67) that the form of the action is reproduced for any dimensionality d of the lattice of the grains. This allows us to write immediately the following renormalization group equation

$$\frac{\partial g(\xi)}{\partial \xi} = -4/z$$

**Valid as long
as $g \geq 1$**

Conclusion from RG analysis:

The solution

$$g_T(T) = g_T - (4/z) \ln (g_T E_C / T) \quad (1)$$

is valid down to $T^* \approx g_T E_C \exp[-(z/4)g_T]$

where $g_T(T^*) \sim 1$

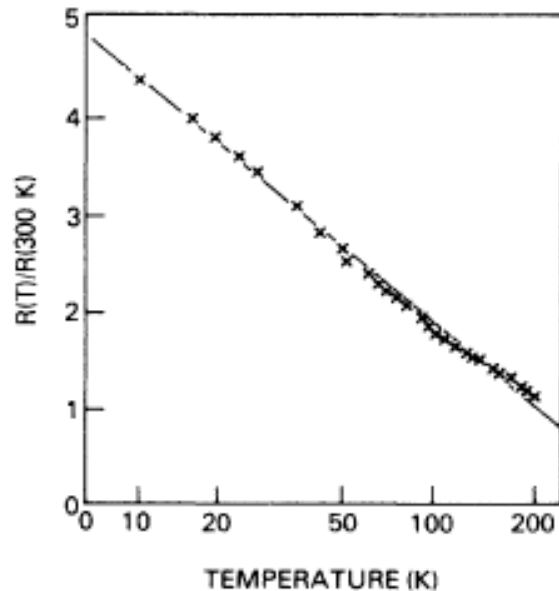
Solution (1) does not coincide with experimental result

$$R(T) = R_0 \ln(T_0/T)$$

What is the reason for disagreement ?

1. R(T) approaching $R_K = h/e^2$

$$R_{\square}(300 \text{ K}) = 2000 \ \Omega/\square,$$



Ratio **thickness/2a** ~ 5

$g_T(300\text{K}) \sim 2$ $g_T(10\text{K}) \sim 0.5$

Condition $g_T \gg 1$ is not fulfilled

2. Distribution of local g_{ij} is broad due to fluctuations of $|d_{ij}|$

$$g_{ij} \propto \exp\{-2k_0 d_{ij}\}$$

RG for disordered granular array

M.Feigelman, A.Ioselevich, M.Skvortsov, Phys.Rev.Lett. **93**, 136403 (2004)

Random initial values of tunneling conductances g_{ij}

Generalized RG equation

$$\frac{dg_{ij}}{dt} = -2g_{ij}R_{ij}$$

instead of

$$g(T) = g_0 - \frac{4}{z} \ln \frac{g_0 E_C}{T},$$

where $t(E) = \ln(\bar{g}_0 E_C / E)$ is the auxiliary RG “time”

R_{ij} is the actual resistance between grains i and j

RG for disordered array: solution

1) the case of relatively narrow original distribution $P_0(g)$: perturbation theory

for the square lattice ($z = 4$):

$$\frac{\sigma(E)}{\bar{g}(E)} = \frac{\sigma_0}{\bar{g}_0} \frac{\bar{g}_0/\bar{g}}{\sqrt{2 \ln(\bar{g}_0/\bar{g}) \ln \ln(\bar{g}_0/\bar{g})}}$$

where $\bar{g} \equiv \bar{g}(E) = \bar{g}_0 - \ln(\bar{g}_0 E_C/E)$

Relative width of the $P(g)$ grows fastly under RG

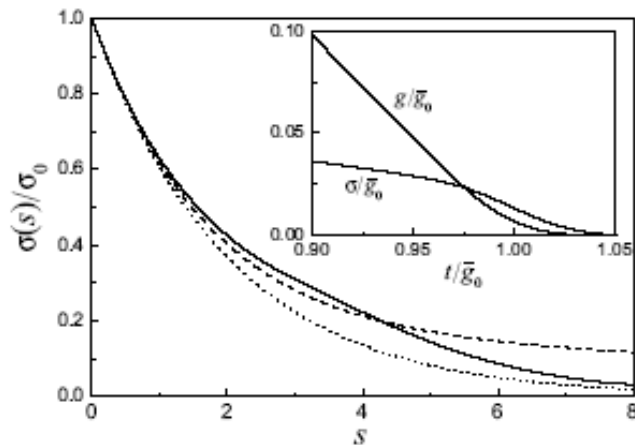


FIG. 2: Evolution of $\sigma(s)/\sigma_0$, Eq. (11), (dashed line), the result of numerical simulation of Eq. (2) with $\sigma_0/\bar{g}_0 = 0.1$ (solid line), and the EMA prediction $e^{-s/2}$ (dotted line). Inset: $\bar{g}(t)$ and $\sigma(t)$ near the MIT.

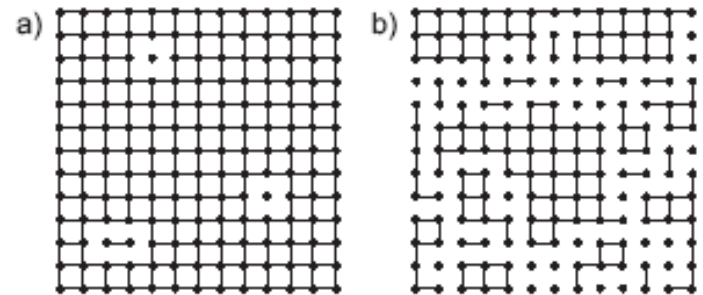


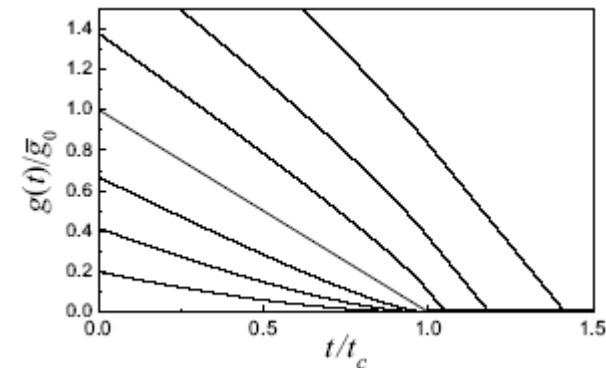
FIG. 1: Conducting bonds (with $g_{ij} > 0$) at different values of t . Results of numerical simulation of Eq. (2) on the lattice 20×20 with $P_0(g) = (2g_0\theta(g)/\pi)/(g^2 + g_0^2)$. a) $t = 0.64g_0$ with the fraction of conducting bonds $N_{\text{cond}} = 0.95$; b) $t = 1.08g_0$ with $N_{\text{cond}} = 0.55$.

RG for disordered array: solution-2

2) Strong disorder: effective-medium approximation

$$R_{ij} = \left[g_{ij} + \left(\frac{z}{2} - 1 \right) g_{\text{eff}} \right]^{-1} \quad \langle R_{ij} (g_{ij} - g_{\text{eff}}) \rangle_{g_{ij}} = 0.$$

$$\int_0^\infty P_0(g_0) dg_0 \frac{g[g_0, \{g_{\text{eff}}\}|t] - g_{\text{eff}}(t)}{g[g_0, \{g_{\text{eff}}\}|t] + \left(\frac{z}{2} - 1 \right) g_{\text{eff}}(t)} = 0$$



Explicit solution for symmetric distributions of $\ln g \sim h_{ij} = \kappa(d_{ij} - \bar{d})$

$$\text{for } t < t_c,$$

$$g_{ij}(t) = \left[\frac{g_{ij}(0) - \bar{g}_0}{2\sqrt{g_{ij}(0)}} + \sqrt{\frac{[g_{ij}(0) + \bar{g}_0]^2}{4g_{ij}(0)} - t} \right]^2$$

$$\underline{g_{\text{eff}}(t) = \bar{g}_0 - t \text{ for } t < t_c = \bar{g}_0}$$

while for $t > t_c$

$$g_{ij}(t) = [g_{ij}(t_c) - 2(t - t_c)] \theta[g_{ij}(t_c) - 2(t - t_c)].$$

RG for disordered array: solution-3

“Universal temperature dependence of the conductivity of a strongly disordered granular metal”

A. R. Akhmerov, A. S. Ioselevich JETP Lett. **83**(5), 211-216 (2006); [cond-mat/0602088](https://arxiv.org/abs/cond-mat/0602088)

$$g_{ij} = \bar{g}_0 e^{h_{ij}}, \quad h_{ij} = -2\kappa(d_{ij} - \langle d \rangle), \quad \Delta \equiv \sqrt{\langle h^2 \rangle} \gg 1$$

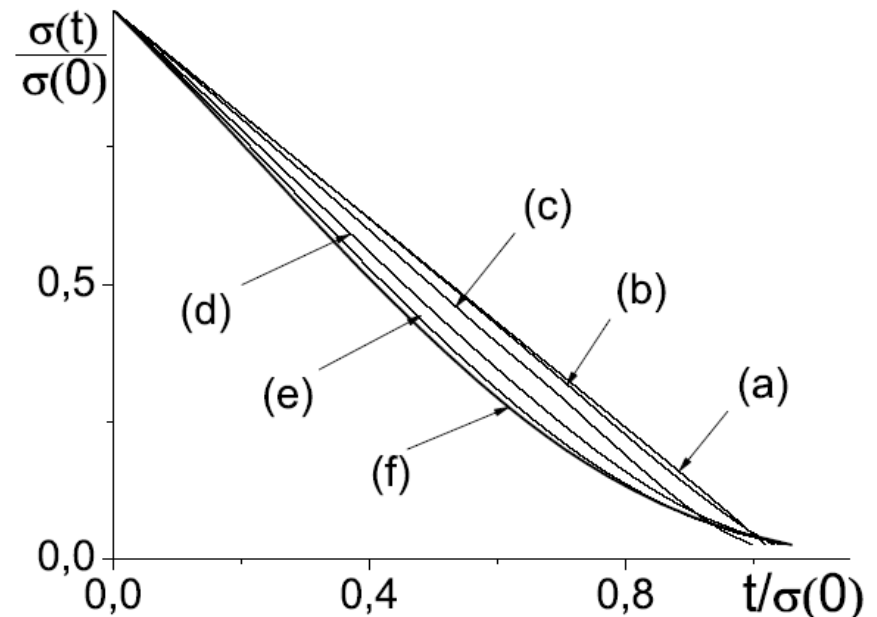
Universal solution:

$$\frac{G_{\square}(T)}{G_{\square}(T_R)} = F^{(2)} \left[\frac{\ln(T_R/T)}{G_{\square}(T_R)} \right],$$

Conclusion:

strong disorder in h_{ij}
might be a reason for

$$R(T) = R_0 \ln(T_0/T)$$



4) Insulating behaviour: co-tunneling and Efros-Shklovsky law

Usual hopping insulator (doped semiconductor): Mott law

$t_{ij} \sim \exp(-r_{ij}/a)$ a is the localization length of Hydrogen-like orbital

$P_{ij} \sim \exp(-2r_{ij}/a) \exp(-\epsilon_{ij}/T)$ ϵ_{ij} is the energy difference between states i and j

$\epsilon_{ij} \sim (r_{ij})^{-d} \nu^{-1}$ Optimize over r_{ij} : $\min_R (2R/a + 1/R^d T)$

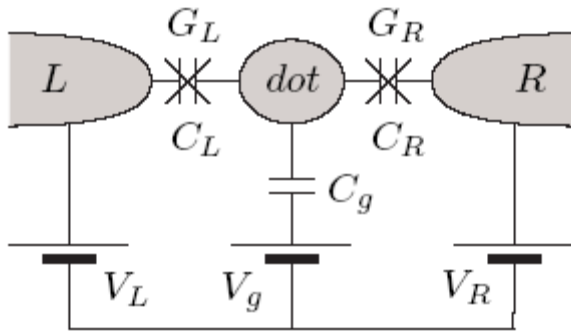
$P_{opt} \sim \exp[-(T_M/T)^a]$ $a = 1/(d+1)$

Doped semiconductor with a Coulomb gap: ES law

$\nu(\epsilon) \sim \epsilon^{d-1} \Rightarrow \epsilon(R) \sim 1/R$ Now R_{opt} is found from
 $\min_R (2R/a + \text{const}/RT)$

$\Rightarrow P_{opt} \sim \exp[-(T_o/T)^{1/2}]$ $T_o = C e^2/\kappa a$

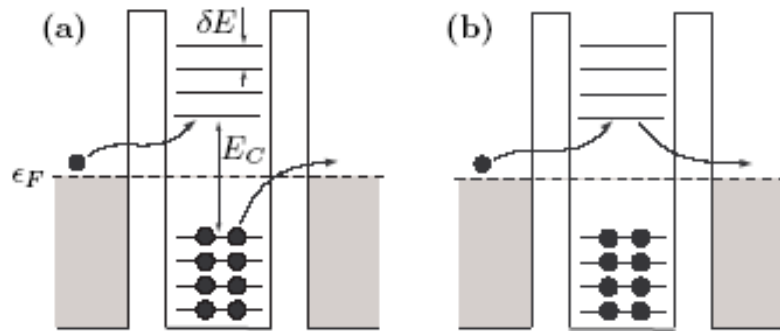
Co-tunneling: correlated tunneling



$$G_{\text{orto}} \sim \min(g_L, g_R) \exp(-E_C/T)$$

Consider now 2-nd order amplitude with charged grain in a virtual state
 (Averin & Nazarov PRL 65, 2446, 1990)

Review: Leonid I. Glazman¹ and Michael Pustilnik² cond-mat/0501007



(a) inelastic co-tunneling

(b) elastic co-tunneling:

Level widths:

$$\Gamma_{\alpha n} = \pi \nu |t_{\alpha n}^2|$$

$$G_{\alpha} = \frac{4e^2}{h} \frac{\Gamma_{\alpha}}{\delta E}$$

Co-tunneling: inelastic and elastic

Inelastic:

$$A_{n,m} = \frac{t_{Ln}^* t_{Rm}}{E_C}$$

$$G_{in} \sim \frac{e^2}{h} \sum_{n,m} \nu^2 |A_{n,m}^2| \sim \frac{e^2}{h} \frac{1}{E_C^2} \sum_{n,m} \Gamma_{Ln} \Gamma_{Rm}, \quad \text{Number of terms} \sim T/\delta E$$

$$\overline{G_{in}} \sim \left(\frac{T}{\delta E} \right)^2 \frac{e^2}{h} \frac{\Gamma_L \Gamma_R}{E_C^2} \sim \frac{G_L G_R}{e^2/h} \left(\frac{T}{E_C} \right)^2$$

Elastic:

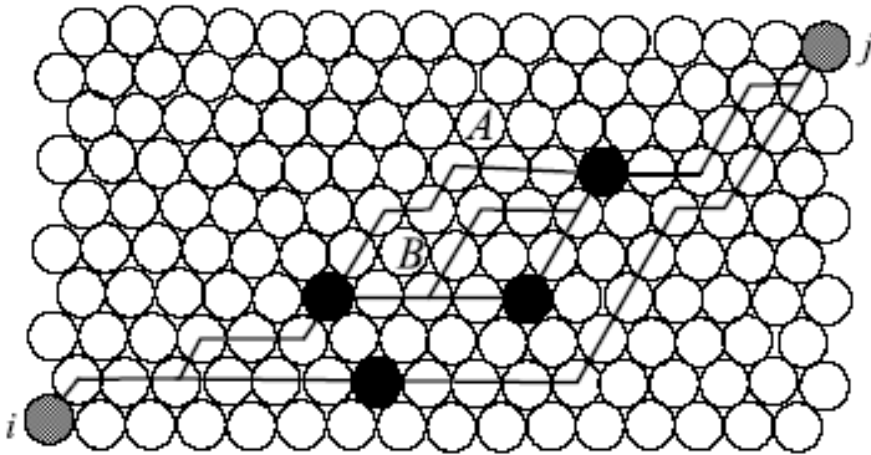
$$A_{el} = \sum_n t_{Ln}^* t_{Rn} \frac{\text{sign}(\epsilon_n)}{E_C + |\epsilon_n|} \quad \overline{|A_{el}^2|} = \frac{\Gamma_L \Gamma_R}{(\pi\nu)^2} \sum_n (E_C + |\epsilon_n|)^{-2}$$

$$G_{el} = \frac{4\pi e^2 \nu^2}{\hbar} |A_{el}^2| \sim \frac{G_L G_R}{e^2/h} \frac{\delta E}{E_C}$$

Variable range cotunneling and conductivity of a granular metal

M. V. Feigel'man¹⁾, A. S. Ioselevich¹⁾

Pis'ma v ZhETF, vol. 81, iss. 6, pp. 341 – 347



Four different strings contributing to the $i \rightarrow j$ transition in a particular realization of array. For a shown partition (“inelastic grains” $\{l\}$ are depicted as filled circles, elastic grains $\{m\}$ – as open ones) only two strings (A and B) contribute to interference effects

$$g_{ij} \propto e^{-\frac{\epsilon_{ij}}{T}} \left(\frac{t}{E_C} \right)^{2N} \times \sum_{L=0}^N \frac{\left(\frac{2|\Delta_{ij}|^2}{\delta^2} \right)^L \left(\frac{E_C}{\delta} \right)^{N-L}}{(2L+1)!} F_{NL}.$$

N is the total grain number in the path

L is the number of “inelastic” grains

$$\Delta_{ij} = \epsilon_j - \epsilon_i - E_c^{(ij)}$$

General expression can be analyzed for local Coulomb only (screening by gate)

Variable range cotunneling - limiting cases

$$g_{ij} \propto \exp\left\{-\frac{\varepsilon_{ij}}{T}\right\} \begin{cases} \left(\frac{\bar{A}_1 g \delta}{8\pi^2 E_C}\right)^{N_{ij}}, & \text{elastic,} \\ \left(\frac{e^2 \bar{A}_2 g |\Delta_{ij}|^2}{16\pi^2 N_{ij}^2 E_C^2}\right)^{N_{ij}}, & \text{inelastic,} \end{cases} \quad \begin{array}{l} g \equiv Gh/e^2 = 8\pi^2 (t/\delta)^2 \ll 1 \\ \text{is the average conductance} \\ \text{between neighbouring grains} \end{array}$$

Usual optimization over N and ε leads to

$$\sigma \sim e^{-\sqrt{T_{ES}/T}} \quad \text{with} \quad T_{ES} = \mathcal{L}(T) E_C \quad \text{and}$$

$$\mathcal{L}(T) = \begin{cases} c_1 \ln\left(\frac{8\pi^2 E_C}{\bar{A}_1 g \delta}\right), & T \ll T_c, \\ c_1 \ln\left(\frac{16\pi^2 E_C^2}{e^2 \bar{A}_2 g T^2 \mathcal{L}^2}\right), & T \gg T_c, \end{cases} \quad \begin{array}{l} T_{ES} \propto a^{-1} \\ T_c \propto a^{-2}. \end{array}$$

crossover temperature $T_c \sim \sqrt{E_C \delta} / \mathcal{L}$.

Variable-range co-tunneling: estimates

Example: Al grains with $a=20$ nm

$$\delta = 0.02 \text{ K} \quad E_{\text{th}} = 50 \text{ K} \quad E_c = 1000 \text{ K}$$

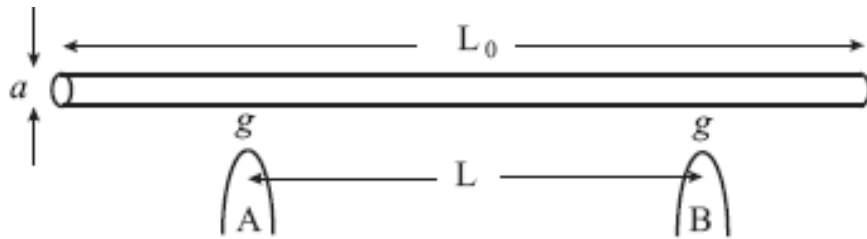
With $g \sim 0.3$ one finds $\mathcal{L} \approx 10$

Thus $T_{\text{ES}} \approx 10^4 \text{ K}$ and $T_c \approx 0.5 \text{ K}$

Conclusions: inelastic co-tunneling dominates,
magneto-resistance is very weak

5) Co-tunneling and conductance of weakly coupled quasi-1D wire

M.V.Feigel'man and A.S.Ioselevich, JETP Lett. **88**, 767-771 (2008); [arXiv:0809.1325](https://arxiv.org/abs/0809.1325)



Experimental results:

$$G \equiv dI/dV \propto V^\alpha \quad (\text{low } T), \quad G \propto T^\alpha \quad (\text{high } T).$$

Usual view: “Luttinger Liquid”

However, such a scaling is observed for multi-channel diffusive conductors

Our explanation: inelastic co-tunneling + Coulomb anomaly

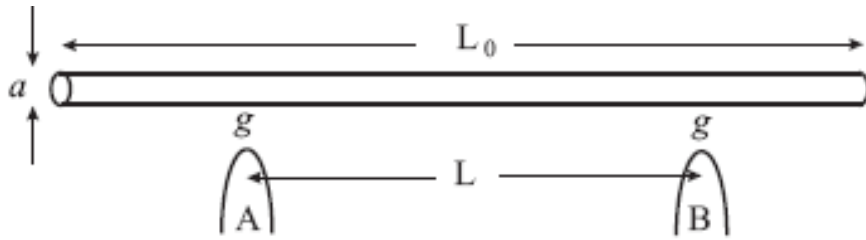


FIG. 1: Electrons tunnel between a wire of length L_0 and diameter a and two leads A and B , placed symmetrically with respect to the center of the wire, at distance L from each other.

weak tunnel contacts A and B with conductances $g \ll 1$

Total classical resistance

$$R(L)/(h/e^2) \equiv L/\xi \gtrsim 1.$$

$\xi \sim N_{\text{ch}}l$ is the localization length, l is the mean free path, and $N_{\text{ch}} \gg 1$ is the number of channels.

We consider relatively high temperatures, i.e. **no** Anderson localization:

$$T \gg T_{\text{Loc}} \sim D\xi^{-2} \sim v_F/N_{\text{ch}}^2l.$$

Our main result reads as follows:

$$G_{AB}^{(2)} \sim g^2 \left(\frac{\max(T, eV)}{E_C(L)} \right)^{\alpha^*} \quad \text{where} \quad \alpha^* = \frac{R(L)}{(h/2e^2)}$$

Exponentially suppressed in L/ξ - in spite of the absence of localization

Coulomb zero-bias anomaly

- A.Finkelstein ZhETF 1984
- Yu.Nazarov ZhETF 1989
- L.Levitov & A.Shytov cond-mat/9607136

$$\boxed{g \rightarrow g e^{-S(T)}} \quad S(T) \quad \text{is the Action of charge spreading process}$$

$$S \sim \int_T \frac{d\omega}{2\pi\omega} \int_{1/\xi} \frac{d^d \mathbf{q}}{(2\pi)^d} \frac{U_q}{\omega + \sigma_q q^2 U_q}, \quad J(\mathbf{q}, \omega)$$

Potential energy $U_q = 2\pi e^2/q$ Source term: $\dot{\mathcal{J}}_1 = [\delta(\tau + \tau_0) - \delta(\tau - \tau_0)] \delta(x + \dot{L}/2)$

$$U_q = 2\pi e^2/q$$

Usual result in quasi-1D:

$$S_1(T, V) \approx \begin{cases} 0.76 \sqrt{\frac{E_C(\xi)}{T}}, & \text{for } eV \ll \sqrt{E_C(\xi)T}, \\ E_C(\xi)/(eV), & \text{for } eV \gg \sqrt{E_C(\xi)T}. \end{cases}$$

Coulomb anomaly + inelastic co-tunneling

$$\boxed{g \rightarrow g e^{-S(T)}} \quad \boxed{S \sim \int_T \frac{d\omega}{2\pi\omega} \int_{1/\xi} \frac{d^d \mathbf{q}}{(2\pi)^d} \frac{U_q}{\omega + \sigma_q q^2 U_q}, J(\mathbf{q}, \omega)}$$

The crucial point of our approach is that we describe tunnelling through a diffusive wire by the same semi-classical equations (11,12), but with modified source

$$\mathcal{J}_2 = [\delta(\tau + \tau_0) - \delta(\tau - \tau_0)][\delta(x + L/2) - \delta(x - L/2)] \quad \mathcal{J}_2(\omega, q) = -4i \sin(\omega\tau_0) \sin(qL/2)$$

which describes *simultaneous* tunnelling of an electron and a hole via both contacts.

In the case of high voltage

$$S_2(T, V \rightarrow 0) \approx \frac{2L}{\xi} \ln \left(\frac{\omega_{\max}}{T} \right) \quad \tilde{S}_2(T, \tau_0) \approx \frac{2L}{\xi} \ln(\omega_{\max} \tau_0), \quad \tau_0^* = \frac{4L(eV)}{\xi},$$